

DOCKET NO.: 289855US0PCT

IN THE UNITED STATES PATENT & TRADEMARK OFFICE

IN RE APPLICATION OF: :
LAURENT LABROUSSE, ET AL. : EXAMINER: LIAO, DIANA
SERIAL NO: 10/576,724 :
FILED: DECEMBER 13, 2006 : GROUP ART UNIT: 1793
FOR: SUBSTRATE, IN PARTICULAR :
GLASS SUBSTRATE, SUPPORTING AT
LEAST ONE STACK OF A
PHOTOCATALYTIC LAYER AND A
SUBLAYER FOR THE
HETEROEPITAXIAL GROWTH OF SAID
LAYER

REQUEST FOR RECONSIDERATION

COMMISSIONER FOR PATENTS
ALEXANDRIA, VIRGINIA 22313

SIR:

In response to the Office Action dated June 11, 2009, reconsideration and allowance are respectfully requested in view of the following remarks.

Claims 1-20 are pending, claims 14-19 having been withdrawn from consideration.

Withdrawn Claims

For the reasons set forth below, Applicants submit that all pending claims presently subject to examination are in condition for allowance. Because withdrawn claims depend from, and thus recite all features of, allowable claims, rejoinder and allowance of the withdrawn claims are respectfully requested.